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(21)Application number : 2001-085338 (71)Applicant : TOYOTA CENTRAL RES &
DEV LAB INC
AISIN SEIKI CO LTD

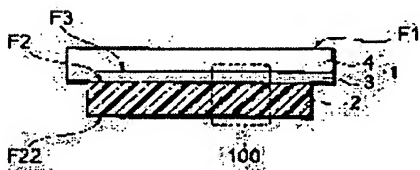
(22)Date of filing : 23.03.2001 (72)Inventor : KATO NAOHIKO
HIGUCHI KAZUO
AZUMA HIROZUMI
MOTOHIRO TOMOMI
FUKUMOTO SHUNGO
TOYAMA TOMOYUKI
TOYODA TATSUO

(54) MANUFACTURING METHOD OF PHOTOELECTRODE FOR DYE
SENSITIZED SOLAR CELL AND MANUFACTURING METHOD OF DYE
SENSITIZED SOLAR CELL

(57)Abstract:

PROBLEM TO BE SOLVED: To provide a manufacturing method of a photoelectrode for a dye sensitized solar cell, showing an excellent photoelectric transducing efficiency, and a manufacturing method of a dye sensitized solar cell.

SOLUTION: The manufacturing method of the photoelectrode 10 for a dye sensitized solar cell, comprising a semiconductor electrode 2 with a light receiving surface F2 and a transparent electrode 1 arranged to adjoin the light receiving surface of the semiconductor electrode, is characterized in that it comprises a surface treatment process wherein electromagnetic waves within a wavelength range of 180-450 nm are emitted to the back surface F22 on the opposite side of the light receiving surface of the semiconductor electrode, and a pigment



adsorption process wherein sensitizing pigment P2 is adsorbed to the back surface obtained through the surface treatment process.

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